Search Notes

Application/Control No.	Applicant(s)/Patent under Reexamination	
09/650,218	AVERY ET AL.	
Examiner	Art Unit	
Shin-Hon Chen	2131	

SEARCHED					
Class	Subclass	Date	Examiner		
713	200, 201	7/28/2005	S.C.		
709	219, 217	7/28/2005	S.C.		
709	230, 328	7/28/2005	S.C.		
382	124, 188	8/1/2005	S.C.		
340	825.31	8/1/2005	S.C.		
340	825.34, 5	8/2/2005	S.C.		
340	5.5	8/2/2005	S.C.		
49	68	8/3/2005	S.C.		
382	. 115	8/3/2005	S.C.		
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INTERFERENCE SEARCHED					
Class	Subclass	Date	Examiner		
709	219,217	7/28/2005	s.c.		
382	115, 124	8/1/2005	S.C.		
340	825.31	8/1/2005	S.C.		
340/825.34, 5.5, 5.81- 5.86; 49/68		8/3/2005	S.C.		

SEARCH NOT (INCLUDING SEARCH) .
	DATE	EXMR
EAST	7/28/2005 ·	S.C.
NPL, EIC Search	8/1/2005	s.c.
Consulted with examiner Chris Revak, Ho Song	8/2/2005	S.C.
Consult with Tech Center 2635 primary examiner Edwin Holloway	8/3/2005	s.c.
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